

EAST Search History**EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	67914	sulfur trioxide or "so.sub.3"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:24
L2	8883	I1 with gas\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:25
L3	136	I2 and photoresist	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:25
L4	0	I2 and (photoresist ro resist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:25
L5	409	I2 and (photoresist or resist)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:25
L6	83	I5 and rins\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:26

L7	594	waleh.in. or levenson.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:39
L8	35	waleh.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:39
L9	37	waleh.in. or (levenson.in. and eric.in.)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:40
L10	10	(waleh.in. and ahmad.in.) or (levenson.in. and eric.in.)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2011/07/11 07:40

EAST Search History (Interference)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L11	44028	(sulfur trioxide). clm. or "so.sub.3"	USPAT; UPAD	ADJ	ON	2011/07/11 07:43
L12	11780	(sulfur trioxide). clm. or "so.sub.3". clm.	USPAT; UPAD	ADJ	ON	2011/07/11 07:43
L13	3009	I12 and (photoresist or resist or organic). clm.	USPAT; UPAD	ADJ	ON	2011/07/11 07:44
L14	60	I12 and (photoresist or resist or organic). clm. and rins\$4. clm.	USPAT; UPAD	ADJ	ON	2011/07/11 07:44

L15	1272	I12 and (photoresist or resist or organic). clm. and (rins\$4. clm. or solvent. clm.)	USPAT; UPAD	ADJ	ON	2011/07/11 07:45
L16	228	I12 and (photoresist or resist or organic). clm. and (rins\$4. clm. or solvent. clm.) and remov \$4.clm.	USPAT; UPAD	ADJ	ON	2011/07/11 07:45
L17	20	I12 and (photoresist or resist or organic). clm. and (rins\$4. clm. or solvent. clm.) and remov \$4.clm. and (remov\$4.ti. or stripp\$4.ti.)	USPAT; UPAD	ADJ	ON	2011/07/11 07:47

7/11/11 7:52:29 AM

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